

PRODUCT/PROCESS CHANGE NOTIFICATION

PCN IPG-PWR/14/8488 Dated 21 May 2014

DPAK Back-End Line relocation from Longgang to Shenzhen (China)

Table 1. Change Implementation Schedule

Forecasted implementation date for change	14-May-2014
Forecasted availability date of samples for customer	14-May-2014
Forecasted date for STMicroelectronics change Qualification Plan results availability	14-May-2014
Estimated date of changed product first shipment	20-Aug-2014

Table 2. Change Identification

Product Identification (Product Family/Commercial Product)	see attached list
Type of change	Package assembly location change, Package assembly process change, Testing location change
Reason for change	Improve service to Customers
Description of the change	Continuing in the already announced plan of consolidating assembly and testing activities, please be informed that we're going to transfer the Assembly/Testing DPAK line for selected Power BIPOLAR Transistors, currently produced in Longgang to Shenzhen (China). DPAK device products, manufactured in Shenzhen (China), guarantee the same quality and electrical characteristics as reported in the relevant data sheets. Devices used for qualification are available as samples.
Change Product Identification	"GK" marked on the package
Manufacturing Location(s)	

Table 3. List of Attachments

Customer Part numbers list	
Qualification Plan results	

Customer Acknowledgement of Receipt	PCN IPG-PWR/14/8488
Please sign and return to STMicroelectronics Sales Office	Dated 21 May 2014
Qualification Plan Denied	Name:
Qualification Plan Approved	Title:
	Company:
🗖 Change Denied	Date:
Change Approved	Signature:
Remark	

Name	Function
Mottese, Anna	Marketing Manager
Aleo, Mario-Antonio	Product Manager
Falcone, Giuseppe	Q.A. Manager

DOCUMENT APPROVAL

Dear Customer,

Continuing in the already announced plan of consolidating assembly and testing activities, please be informed that we're going to transfer the Assembly/Testing DPAK line for selected Power BIPOLAR Transistors, currently produced in Longgang to Shenzhen (China). DPAK device products, manufactured in Shenzhen (China), guarantee the same quality and electrical characteristics as reported in the relevant data sheets. Devices used for qualification are available as samples.

The involved product series and affected packages are listed in the table below:

Product Family Description	Package	Commercial Product / Series
Power BIPOLAR Transistors	DPAK	STDxxx

Any other Product related to the above series, manufactured in ST Shenzhen, even if not expressly included or partially mentioned in the attached table, is affected by this change.

Qualification program and results availability:

The reliability test report is provided in attachment to this document.

Samples availability:

Samples of the test vehicle devices will be available on request starting from week 20-2014. Any other sample request will be processed and scheduled by Power Transistor Division upon request.

Product Family Description	Package	Part Number - Test Vehicle
Power BIPOLAR Transistors	DPAK	STD13003T4

Change implementation schedule:

The production start and first shipments will be implemented according to our work in progress and materials availability:

Product Family	1st Shipments
Power BIPOLAR Transistors	From Week 34-2014

Lack of acknowledgement of the PCN within 30 days will constitute acceptance of the change. After acknowledgement, lack of additional response within the 90 days period will constitute acceptance of the change (Jedec Standard No. 46-C). In any case, first shipment may start earlier with customer written agreement.

Marking and traceability:

Unless otherwise stated by customer specific requirement, traceability of Power BIPOLAR Transistors produced in ST Shenzhen will be ensured by the Q.A. number and plant code identification "GK" marked on the package.

Sincerely Yours.





Reliability Report

DPAK Back-End Line relocation from Longgang to Shenzhen (China) for selected Power BIPOLAR Transistors.

Genera	I Information	Locations	
Product Lines:	BV77	Wafer Diffusion Plants:	Tours (France) Ang Mo Kio (Singapore)
Product Families:	Power BIPOLAR	EWS Plants:	Tours (France) Ang Mo Kio (Singapore)
P/Ns:	STD13003T4		
Lot1: Lot2:	U329037 (TOURS) W338T9Y (AMK)	Assembly and testing plant:	ST Shenzhen (China)
Product Group:	IPG	Reliability Lab:	IPG-PTD Catania Reliability Lab.
Product division:	Power Transistor Division		
Package:	DPAK		
Silicon Process techn.:	Power BIPOLAR		

DOCUMENT INFORMATION

Version	Date	Pages	Prepared by	Approved by	Comment
1.0	May2014	6	A. Settinieri	C. Cappello	First issue

Note: This report is a summary of the reliability trials performed in good faith by STMicroelectronics in order to evaluate the potential reliability risks during the product life using a set of defined test methods.

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<u>1</u> APPLICABLE AND REFERENCE DOCUMENTS

Document reference	e Short description	
JESD47	Stress-Test-Driven Qualification of Integrated Circuits	

2 GLOSSARY

DUT	Device Under Test
SS	Sample Size
HF	Halogen Free

<u>3 RELIABILITY EVALUATION OVERVIEW</u>

3.1 Objectives

Reliability evaluation for assembly and testing transfer from the ST plant of Longgang to ST Shenzhen for selected Power BIPOLAR Transistors related to the products housed in DPAK package.

3.2 Conclusion

Qualification Plan requirements have been fulfilled without exception. It is stressed that reliability tests have shown that the devices behave correctly against environmental tests (no failure). Moreover, the stability of electrical parameters during the accelerated tests demonstrates the ruggedness of the products and safe operation, which is consequently expected during their lifetime.



4 DEVICE CHARACTERISTICS

4.1 **Device description**

NPN Power BIPOLAR

4.2 Construction note

D.U.T.:STD13003T4 LINE: BV77 PACKAGE: DPAK

Wafer/Die fab. Information				
Wafer fab manufacturing location	Lot1: Tours (France)			
	Lot2: Ang Mo Kio (Singapore)			
Technology	Power BIPOLAR NPN			
Die finishing back side	Lot1: Ti/Ni/Au Tours (France)			
	Lot2: Ti/Ni/Ag Ang Mo Kio (Singapore)			
Die size	1320 x 1390 µm ²			
Metal	Al/Si			
Passivation type	Nitride			

Wafer Testing (EWS) information			
Electrical testing manufacturing location	Lot1: Tours (France)		
	Lot2: Ang Mo Kio (Singapore)		
Test program	WPIS		

Assembly information			
Assembly site	ST Shenzhen (China)		
Package description	DPAK		
Molding compound	HF Epoxy Resin		
Frame material	Raw Copper		
Die attach process	Soft Solder		
Die attach material	Pb/Sn/Ag		
Wire bonding process	Ultrasonic		
Wires bonding materials	Cu		
Lead finishing/bump solder material	Pure Tin		

Final testing information		
Testing location	ST Shenzhen (China)	
Tester	TESEC	



5 TESTS RESULTS SUMMARY

5.1 Test vehicle

Lot #	Process/ Package	Product Line	Comments
1	STD12002T1	BV77	Power BIPOLAR (Tours)
2	STD13003T4	BV77	Power BIPOLAR (AMK)

5.2 **Reliability test plan summary**

D.U.T.: STD13003T4

LINE: BV77

PACKAGE: DPAK

		-				Failure/SS		Note
Test	PC	Std ref.	Conditions	SS	Steps	Lot 1 TOURS	Lot 2 AMK	
Die Orier	nted	Tests						
					168 H	0/77	0/77	
HTRB	Ν	JESD22 A-108	Tj = 150°C, BIAS=560V	154	500 H	0/77	0/77	
					1000 H	0/77	0/77	
Package	Orie	ented Tests			-		-	
PC		JESD22 A-113	Drying 24 H @ 125°C Store 168 H @ Ta=85°C Rh=85% Over Reflow @ Tpeak=260°C 3 times	462	Final	0/231	0/231	
AC	Y	JESD22	Pa=2Atm / Ta=121°C	154	96 H	0/77	0/77	
					100 cy	0/77	0/77	
тс	Y	JESD22 A-104	Ta = -65°C to 150°C	154	200 cy	0/77	0/77	
					500 cy	0/77	0/77	
					168 H	0/77	0/77	
тнв	Y	JESD22 A-101	Ta = 85°C, RH = 85%, BIAS=100V	154	500 H	0/77	0/77	
					1000 H	0/77	0/77	



6 ANNEXES 6.0

<u>6.1Tests Description</u>

Test name	Description	Purpose			
Die Oriented Tests	Die Oriented Tests				
HTRB High Temperature Reverse Bias	 The device is stressed in static configuration, trying to satisfy as much as possible the following conditions: low power dissipation; max. supply voltage compatible with diffusion process and internal circuitry limitations; 	To determine the effects of bias conditions and temperature on solid state devices over time. It simulates the devices' operating condition in an accelerated way. To maximize the electrical field across either reverse-biased junctions or dielectric layers, in order to investigate the failure modes linked to mobile contamination, oxide ageing, layout sensitivity to surface effects.			
Package Oriented 1	ests				
PC Preconditioning	The device is submitted to a typical temperature profile used for surface mounting devices, after a controlled moisture absorption.	As stand-alone test: to investigate the moisture sensitivity level. As preconditioning before other reliability tests: to verify that the surface mounting stress does not impact on the subsequent reliability performance. The typical failure modes are "pop corn" effect and delamination.			
AC Auto Clave (Pressure Pot)	The device is stored in saturated steam, at fixed and controlled conditions of pressure and temperature.	To investigate corrosion phenomena affecting die or package materials, related to chemical contamination and package hermeticity.			
TC Temperature Cycling	The device is submitted to cycled temperature excursions, between a hot and a cold chamber in air atmosphere.	To investigate failure modes related to the thermo-mechanical stress induced by the different thermal expansion of the materials interacting in the die-package system. Typical failure modes are linked to metal displacement, dielectric cracking, molding compound delamination, wire-bonds failure, die-attach layer degradation.			
H3TRB Temperature Humidity Bias	The device is biased in static configuration minimizing its internal power dissipation, and stored at controlled conditions of ambient temperature and relative humidity.	To evaluate the package moisture resistance with electrical field applied, both electrolytic and galvanic corrosion are put in evidence.			

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